**Carver Alumni Scholarship Application**
**Atlanta Chapter of the Carver Alumni Association (ACCAA) 2024**
Type or Print neatly using ink.

First Name: Cailey Last Name: Monk Date of Birth: October 10,2006

Home Address: 4837 shenandoah drive City/State/Zip: columbus Ga ,31907

Home Phone w/area code 706-575-2350 Parent's work phone _____

Name of Parent/Guardian: Christal Cobb Parent e-mail Baker.christal82@gmail.com

Alternate Family Member Name & Phone: Kevin Cobb 313-409-7106

Your e-mail: caileycobb15@gmail.com Counselor: Audery Whitaker

High School: Hardaway High School Class of: 2025 Cumulative GPA: 3.2

Name of Carver ancestor: Laura Williams Jackson - Class 1965

What college/university are you currently attending? Albany State University

Field of Study (Major): Dental Hygiene

Why did you choose this field of study?

I choose this field of study because I want to become a pediatric dentist and the reason being is because I really love kids as well as teeth. I want to make kids enjoy coming to the dentist ! I want to be a light to little ones and show you can do anything you put your mind to.

I verify that the information on this application is true and correct:

Student's signature: Cailey Monk Date: April 7,2025

**Requirements for Application:**

- Must be a descendent of a Carver High School (Hamilton, Ga.) alumnus
- Must be currently enrolled in an accredited college as a full time student for Winter 2024.
- Must be actively pursuing a bachelors, graduate or doctorate degree.
- Must have a cumulative GPA of 3.0 or better (certified transcript required).
- Must provide a minimum 300 word essay on one of the scholarship topics (see website).
- Application **must be received by Monday, April 15, 2024.**

Mail completed application to:

ACCAA, Inc.
P.O. Box 361914
Decatur, Ga. 30036
Phone: (770) 987-8663

*This form is for **current college students** who are descendants of Carver Alumni (Hamilton, GA), currently enrolled in college or university, have a 3.0 cumulative GPA and who meet other eligibility requirements.